PRELIMINARY COMMUNICATION

CHEMICAL PROPERTIES OF THE SILICON-IRON BOND IN TRIMETHYLSILYL *n*-CYCLOPENTADIENYLIRON DICARBONYL

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This investigation was carried out for the purpose of examining the littlestudied^{1, 2} chemical properties of the silicon—iron bond in Me₃Si—Fe(CO)₂ (π -C₅H₅) in order to determine how they differed from those of this bond in (H₃Si)₂Fe(CO)₄⁴ and from those of the silicon—metal bonds in Me₃Si—Co(CO)₄ and Me₃Si—Mn(CO)₅⁵⁻⁷. The silicon—iron bond in this compound is surprisingly inert and in certain ways it tends to resemble the silicon—phenyl linkage.

When heated *in vacuo* at 160° for one hour, $Me_3Si-Fe(CO)_2(\pi-C_5H_5)$ [τ , 9.64 (Me_3Si) and 5.45 (π -C₅H₅), 5% in cyclohexane] did not undergo thermal decomposition. A darkening in color and a trace of (Me_3Si)₂O were apparent after one hour at 200°. When solid Me_3Si-Fe(CO)_2(π -C₅H₅) was exposed to 0.7 atmosphere of dry oxygen for four days, approximately 70% of the original material was recovered unchanged.

Solid Me₃Si-Fe(CO)₂ (π -C₅H₅) underwent no reaction with liquid water (1/5 molar ratio) during one day at room temperature; even when its solution in ether was treated with a 1/6 molar excess of water for one hour at room temperature, it could be recovered quantitatively. Analogously, Me₃Si-Fe(CO)₂ (π -C₅H₅) was recovered from its solution in methanol (1/1 molar ratio) which had stood at room temperature for one hour.

Unlike Me₃Si-Co(CO)₄⁷ and Me₃Si-Mn(CO)₅⁶, which underwent instantaneous reaction with trimethylamine to form the trimethylsilyl ammonium compounds, $[Me_3Si-NMe_3]^+[Co(CO)_4]^-$ and $[Me_3Si-NMe_3]^+[Mn(CO)_5]^-$ respectively, Me₃Si-Fe(CO)₂ (π -C₅H₅) was recovered quantitatively from its solution in trimethylamine (1/2 molar ratio) after one hour at room temperature. This is understandable since HFe(CO)₂ (π -C₅H₅) is apparently a much weaker acid than HCo(CO)₄ or HMn(CO)₅⁸.

No reaction occurred during one hour between methyl chloride and $Me_3Si-Fe(CO)_2(\pi-C_5H_5)$ (3/1 molar ratio) which formed a homogeneous solution at room temperature.

 $Me_3Si-Fe(CO)_2(\pi-C_5H_5)$ dissolved in a methanolic solution of KOH (molar ratios $Me_3Si-Fe(CO)_2(\pi-C_5H_5)/KOH/MeOH$; 1.0/1.6/15.9) underwent a slow and incomplete reaction during one hour at room temperature. Only 51% of the Me_3Si- groups originally present in the starting compound had appeared as Me_3SiOMe and $(Me_3Si)_2O^9$.

An infrared spectrum of the solid residue remaining after the reaction showed that it contained unchanged Me₃Si-Fe(CO)₂ (π -C₅H₅) and also the [Fe(CO)₂ (π -C₅H₅)]⁻ ion¹⁰

When a solution of $Me_3Si-Fe(CO)_2(\pi-C_5H_5)$ in dimethylamine (1/2 molar ratio) was held at room temperature a slow reaction occurred, as evidenced by an NMR study. After one hour 25% of the Me_3Si- groups in the starting material were recovered as $Me_3Si-NMe_2$ (eq.1); some $(Me_3Si)_2O$ was also formed. Infrared examination of the less

$$Me_{3}Si-Fe(CO)_{2}(\pi-C_{5}H_{5}) + HNMe_{2} \rightarrow Me_{3}Si-NMe_{2} + HFe(CO)_{2}(\pi-C_{5}H_{5})$$
(1)

volatile products showed unreacted Me₃Si-Fe(CO)₂(π -C₅H₅) and HFe(CO)₂(π -C₅H₅)¹¹, together with some [Fe(CO)₂(π -C₅H₅)]₂^{12, 13}, presumably formed from the partial decomposition of the latter compound.

In marked contrast to the above reactions, solid Me₃Si-Fe(CO)₂(π -C₅H₅) and anhydrous hydrogen chloride (1/3 molar ratio) underwent an extremely rapid reaction while warming from -196° to room temperature, *viz*.

$$Me_{3}Si-Fe(CO)_{2}(\pi-C_{5}H_{5}) + HCl \rightarrow Me_{3}SiCl + HFe(CO)_{2}(\pi-C_{5}H_{5})$$
(2)

After five minutes at room temperature 82% of the Me₃Si-groups in the Me₃Si-Fe(CO)₂ (π -C₅H₅) employed were recovered as Me₃SiCl and (Me₃Si)₂O. HFe(CO)₂ (π -C₅H₅) is known to decompose rapidly at room temperature¹⁴, and it seems possible that some of the Me₃SiCl formed may undergo a complex reaction with it to give the small amount of (Me₃Si)₂O isolated, together with other non-volatile silicon-containing species.

When $Me_3Si-Fe(CO)_2(\pi-C_5H_5)$ was dissolved in a solution of hydrogen chloride in methanol (molar ratios $Me_3Si-Fe(CO)_2(\pi-C_5H_5)/HCl/MeOH; 1.00/0.13/4.17$) and held for one hour at room temperature, most of the $Me_3Si-Fe(CO)_2(\pi-C_5H_5)$ was recovered unchanged. One may write a hypothetical equation for the methanolysis as

$$Me_3Si-Fe(CO)_2(\pi-C_5H_5) + MeOH \rightarrow Me_3SiOMe + HFe(CO)_2(\pi-C_5H_5).$$
 (3)

It is not unreasonable to assume that this reaction is thermodynamically possible as written in view of the strength of the silicon-oxygen bond formed in the product molecule, Me₃ SiOMe, and in view of the observation that both Me₃ Si-Co(CO)₄ and Me₃Si-Mn(CO)₅ undergo rapid methanolysis to give Me₃SiOMe and the corresponding transition metal carbonyl hydride^{5,6}. Since an extensive reaction did not occur in a homogeneous medium when potassium hydroxide or hydrogen chloride was dissolved in a methanolic solution of Me₃Si-Fe(CO)₂ (π -C₅H₅), it would appear that methanolysis is not strongly catalysed by bases such as potassium hydroxide or by acids such as hydrogen chloride or MeOH₂ + ^{15, 16}. This indicates that the silicon in Me₃Si-Fe(CO)₂ (π -C₅H₅) is not readily attacked even by the strong nucleophile OH. It also suggests that the silicon-iron bond does not undergo rapid electrophilic attack at the iron by the electrophile, MeOH₂^{*}, but that an attack at the iron by the more strongly electrophilic hydrogen of hydrogen chloride does readily occur (eq.2) Furthermore, the non-reaction of Me₃Si–Fe(CO)₂ (π -C₅H₅) with trimethylamine and the slow reaction with dimethylamine (eq.1) also indicate that the silicon in the silicon-iron bond is not particularly susceptible to nucleophilic attack by nitrogen. The greater rate of reaction of the silicon-iron bond with hydrogen chloride indicates that the rate-controlling step in the cleavage of this bond might well involve an electrophilic attack at the iron. In this respect the silicon-iron bond is analogous to the silicon-phenyl bond which undergoes electrophilic aromatic attack by hydrogen chloride even at low temperatures¹⁷,

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